Received Event (Event Succee) 12:40 PM Time: Date: 7/9/99 7 min 24 sec **Duration:** 20 Pages: Fax Number: 7162631600 Sender: P. 7/20 No. 9151 NIXON PEABODY LLP Jul. 9.1999 12:41PM **PATENT** Docket No.: 15275/8610 (Dobbins 2-1) IN THE UNITED STATES PATENT AND TRADEMARK OFFICE Examiner: 08/833,620 Reissue Application No. : J. Hoffman April 7, 1997 Filed Art Unit: 1731 5,043,002 U.S. Patent No. August 27, 1991 Granted Michael S. Dobbins and Robert Patentees E. McLay METHOD OF MAKING For FUSED SILICA BY DECOMPOSING SILOXANES AMENDMENT UNDER 37 C.F.R. §1.116 Assistant Commissioner of Patents Washington, D.C. 20231 Box: AF Dear Sir:

In response to the March 9, 1999, final rejection, please amend the aboveidentified patent application as follows:

In the Claims:

Please cancel claims 8-9, 14-18, 18-19, 28-29, and 31-32.

Please amend claims 7, 13, and 17 as follows:

7. (Amended) In a method for making a non-porous body of high purity fused silica glass doped with at least one oxide dopant comprising the steps of:

(a) producing a gas stream containing a silicon-containing compound in vapor form capable of being converted through thermal decomposition with

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